



Dawn

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of)
Xiuhua Zhang) Examiner: Rachuba, Maurina
Application No. 10/743,963) Art Unit: 3723
Filed: December 22, 2003) Docket No. LAM2P456
For: CHEMICAL MECHANICAL PLANARIZATION) Date: August 24, 2005
(CMP) SYSTEM AND METHOD FOR PREPARING)
A WAFER IN A CLEANING MODULE)

CERTIFICATE OF EXPRESS MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service on August 24, 2005, in an envelope as first class mail, addressed to the Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

Signed: Cynthia Dawn
Cynthia Dawn

RESPONSE TO RESTRICTION REQUIREMENT

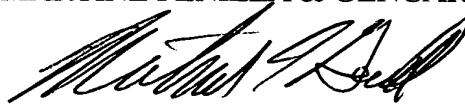
Commissioner for Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Restriction Requirement dated July 28, 2005, Applicants hereby elect, without traverse, Group III, Claims 13-21, to prosecute in the above-identified Patent Application.

Should the Examiner have any questions concerning this matter, the undersigned can be reached at the telephone number set out below.

Respectfully submitted,
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